Electronic Acknowledgement Receipt FES ID: 1236255 Application Number: 10599661 Confirmation Number: 2432 Palladium-plated Lead Finishing Structure For Semiconductor Part And Title of Invention: Method Of Producing Semiconductor Device First Named Inventor: Kazumitsu Seki Customer Number: 54205 Filer: Joseph A. Calvaruso/Susan Shen-Frattura Filer Authorized By: Joseph A. Calvaruso Attorney Docket Number: 17314018 Receipt Date: 04-OCT-2006 Filing Date: Time Stamp: 18:29:40 Application Type: U.S. National Stage under 35 USC 371 International Application Number: Payment information:

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National Stage of an International Application under 35 U.S.C. 371

If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/IDO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filling Receipt, in due course.